

PATENT APPLICATION

**RESPONSE UNDER 37 CFR §1.116
EXPEDITED PROCEDURE
TECHNOLOGY CENTER ART UNIT 1795**

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Satoshi TAKEI et al.

Group Art Unit: 1795

Application No.: 10/544,129

Examiner: A. EOFF

Filed: August 2, 2005

Docket No.: 124936

For: ACRYLIC POLYMER-CONTAINING GAP FILL MATERIAL FORMING
COMPOSITION FOR LITHOGRAPHY

REQUEST FOR RECONSIDERATION AFTER FINAL REJECTION

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In reply to the December 4, 2008 Office Action, reconsideration of the rejection is respectfully requested in light of the following remarks.